

L Number	Hits	Search Text	DB	Time stamp
1	233	438/705.ccls.	USPAT	2001/06/04 05:17
2	118348	nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing	USPAT	2001/06/04 05:40
3	31	438/705.ccls. and (nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing)	USPAT	2001/06/04 05:28
4	590407	selective or selectively	USPAT	2001/06/04 05:28
5	1952	(nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) with (selective or selectively)	USPAT	2001/06/04 05:28
6	129811	etch or etched or etching	USPAT	2001/06/04 05:29
7	152	((nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) with (selective or selectively)) with (etch or etched or etching)	USPAT	2001/06/04 05:29
8	150	((((nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) with (selective or selectively)) with (etch or etched or etching)) not (438/705.ccls. and (nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing)))	USPAT	2001/06/04 05:29
9	82690	nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/06/04 05:44
10	29628	(selective or selectively) and (etch or etching or etched)	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/06/04 05:41
11	432	(nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) and ((selective or selectively) and (etch or etching or etched))	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/06/04 05:41
12	809749	semiconductor	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/06/04 05:41
13	323	((nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) and ((selective or selectively) and (etch or etching or etched))) and semiconductor	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/06/04 05:41
14	21470	(selective or selectively) with (etch or etching or etched)	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/06/04 05:41
15	220	((((nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) and ((selective or selectively) and (etch or etching or etched))) and semiconductor) and ((selective or selectively) with (etch or etching or etched)))	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/06/04 05:42
16	76981	nitrided or nitridation or nitridize or nitridizes or nitridization or ammonia or nitriding or nitridizing	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/06/04 05:44
17	283	((selective or selectively) with (etch or etching or etched)) and (nitrided or nitridation or nitridize or nitridizes or nitridization or ammonia or nitriding or nitridizing)	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/06/04 06:07

18	216	subphotolithographic or "minimum resolution"	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/06/04 06:08
19	0	(nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) and (subphotolithographic or "minimum resolution")	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/06/04 06:08
20	829	subphotolithographic or "minimum resolution"	USPAT	2001/06/04 06:08
21	30	(nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) and (subphotolithographic or "minimum resolution")	USPAT	2001/06/04 06:08
22	30	((nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) and (subphotolithographic or "minimum resolution"))) not (438/705.ccls. and (nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing))	USPAT	2001/06/04 06:12
23	601	(nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) with gate	USPAT	2001/06/04 06:12
24	417	(nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) with polysilicon	USPAT	2001/06/04 06:13
25	63	(selective or selectively) same (((nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) with gate) or ((nitrided or nitridation or nitridize or nitridizes or nitridization or nitrides or ammonia or nitriding or nitridizing) with polysilicon))	USPAT	2001/06/04 06:13